

# UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Addease COMMISSIONER FOR PATENTS PO Box 1430 Alexandra, Virginia 22313-1450 www.webjo.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/559,981	09/05/2006	John Kouvetakis	05-720-US2	6588	
20306 7590 04/17/2008 MCDONNELL BOEHNEN HULBERT & BERGHOFF LLP			EXAM	EXAMINER	
300 S. WACKER DRIVE			PATEL, REEMA		
32ND FLOOR CHICAGO, II			ART UNIT	PAPER NUMBER	
			2812		
			MAIL DATE	DELIVERY MODE	
			04/17/2008	PAPER	

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

# Application No. Applicant(s) 10/559.981 KOUVETAKIS ET AL. Office Action Summary Examiner Art Unit Reema Patel 2812 -- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS. WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION. Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). Status 1) Responsive to communication(s) filed on 21 January 2008. 2a) This action is FINAL. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11, 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-3.5.6 and 10-30 is/are pending in the application. 4a) Of the above claim(s) \_\_\_\_\_ is/are withdrawn from consideration. 5) Claim(s) 1-3,5,6,10-12 and 17-30 is/are allowed. 6) Claim(s) 13-16 is/are rejected. 7) Claim(s) \_\_\_\_\_ is/are objected to. 8) Claim(s) \_\_\_\_\_ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) ☐ The drawing(s) filed on 08 December 2005 is/are: a) ☐ accepted or b) ☐ objected to by the Examiner. Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a). Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152. Priority under 35 U.S.C. § 119 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some \* c) None of: Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). \* See the attached detailed Office action for a list of the certified copies not received. Attachment(s) 1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413) Paper No(s)/Mail Date. \_\_\_

Notice of Draftsperson's Patent Drawing Review (PTO-948)
Information Disclosure Statement(s) (PTO/SB/08)

Paper No(s)/Mail Date 3/10/08

5) Notice of Informal Patent Application

6) Other:

Application/Control Number: 10/559,981 Page 2

Art Unit: 2812

#### DETAILED ACTION

This action is in response to an amendment filed 1/21/08.

### Information Disclosure Statement

 The information disclosure statement (IDS) was submitted on 3/10/08. The submission is in compliance with the provisions of 37 CFR 1.97. Accordingly, the information disclosure statement has been considered by the examiner.

# Claim Rejections - 35 USC § 103

- The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
  - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- Claims 13-15 are rejected under 35 U.S.C. 103(a) as being unpatentable over Soref et al. (U.S. 5,548,128; hereinafter 'Soref') in view of Yoshida (U.S. 2002/0136932 A1).
- 4. Regarding claims 13-15, Soref discloses a semiconductor comprising a Ge-Sn quantum structure formed over a silicon substrate (col 2, lines 45-47). Soref discloses the Ge-Sn quantum structure comprises Ge<sub>ix</sub>Sn<sub>x</sub> with an x value from about 0.02 to about 0.03 (col 2, lines 59-61) and the Ge-Sn quantum structure is formed over Ge-Sn epitaxial layer formed over the silicon substrate (col 3, lines 27-29).
- Soref discloses the active layer comprises a quantum well structure (continuous) and hence not a quantum dot structure (discontinuous). However, Yoshida discloses a semiconductor device with an active layer comprising quantum dots ([0068]-[0077]).

Application/Control Number: 10/559,981 Page 3

Art Unit: 2812

form a more efficient semiconductor device.

hereinafter 'Yamaguchi').

The motivation of using a quantum dot active layer is that it allows for greater efficiency as compared to that of a quantum well active layer ([0077]). Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify Soref with an active layer of quantum dots, as taught by Yoshida, so as to

- 6. Claim 16 is rejected under 35 U.S.C. 103(a) as being unpatentable over Soref et al. (U.S. 5,548,128; hereinafter 'Soref') and Yoshida (U.S. 2002/0136932 A1) as applied to claim 13 above, and further in view of Yamaguchi et al. (2003/0219933 A1;
- 7. Regarding claim 16, Soref and Yoshida discloses the limitations of claim 13 and the use of a silicon substrate but does not disclose that the substrate comprises Si(100). However, Yamauchi discloses that the use of an Si(100) substrate is desirable because an epitaxially grown film formed over such a substrate has a better crystallographic structure as compared to those films formed on other types of substrates ([0083]). Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to modify the invention of Soref and Yoshida with the use of an Si(100) substrate so as to form an epitaxially grown film with better crystallographic structure.

# Allowable Subject Matter

8. Claims 1-3, 5-6, 10-12, and 17-30 are allowed.

Application/Control Number: 10/559,981 Page 4

Art Unit: 2812

9. Claim 1 contains allowable subject matter because of the limitation of forming the  $Sn_xGe_{1\cdot x}$  layer directly over a substrate consisting essentially of silicon. Claims 2-3, 5-6,

10-12, 25-28, and 30 depend on claim 1.

 Claims 17 contain allowable subject matter because of the limitation of forming an epitaxial Ge-Sn layer using a SnD<sub>4</sub> precursor. Claims 18-23 and 29 depend on claim

17.

11. Claim 24 contains allowable subject matter because of the limitation of depositing a strained Ge layer on a GeSn buffer layer with the method of combining SnD<sub>4</sub> with a germanium precursor. Ge<sub>2</sub>H<sub>6</sub>.

### Response to Arguments

 Applicant's arguments with respect to claims 13-16 have been considered but are moot in view of the new ground(s) of rejection.

#### Terminal Disclaimer

13. The terminal disclaimer filed on 1/21/08 disclaiming the terminal portion of any patent granted on this application which would extend beyond the expiration date of U.S. 7,238,596 has been reviewed and is accepted. The terminal disclaimer has been recorded.

#### Conclusion

14. Applicant's amendment necessitated the new ground(s) of rejection presented in this Office action. Accordingly, THIS ACTION IS MADE FINAL. See MPEP § 706.07(a). Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

Application/Control Number: 10/559,981

Art Unit: 2812

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Reema Patel whose telephone number is (571)270-1436. The examiner can normally be reached on M-F, 8:00-4:30 ET.

If attempts to reach the examiner by telephone are unsuccessful, please contact the examiner's acting supervisors, Walter Lindsay, Jr. (571)272-1674 or Scott Geyer (571)272-1958. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

/Reema Patel/ Examiner, Art Unit 2812

/Scott B. Geyer/

Acting SPE of Art Unit 2812